IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Arup Bhattacharyya

Title:

HIGH-PERFORMANCE ONE-TRANSISTOR MEMORY CELL

Docket No.:

1303.111US1

Filed:

July 2, 2003

Examiner:

Unknown

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450



Serial No.: 10/612793

Due Date: N/A

Group Art Unit: 2811

We are transmitting herewith the following attached items (as indicated with an "X"):

- X A return postcard.
- X A Communication Concerning Related Applications (1 pg.).
- X An Information Disclosure Statement (2 pgs.), Form 1449 (2 pgs.), and copies of 20 cited documents.

If not provided for in a separate paper filed herewith, Please consider this a PETITION FOR EXTENSION OF TIME for sufficient number of months to enter these papers and please charge any additional fees or credit overpayment to Deposit Account No. 19-0743.

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

Customer Number 21186

Atty: Marvin L. Beekman

Reg. No. 38,377

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this 35 day of February, 2004.

Name

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

(GENERAL)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Arup Bhattacharyya

Examiner: Unknown

Serial No.:

10/612793

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Filed:

July 2, 2003

Docket: 1303.111US1

C. Kitle:

HIGH-PERFORMANCE ONE-TRANSISTOR MEMORY CELL

COMMUNICATION CONCERNING RELATED APPLICATION(S)

Emmissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Applicant would like to bring to the Examiner's attention the following related application(s) in the above-identified patent application:

Serial/Patent No.	Filing Date	Attorney Docket	<u>Title</u>
10/232855	August 30, 2002	1303.072US1	GATED LATERAL THYRISTOR-BASED
			RANDOM ACCESS MEMORY CELL
			(GLTRAM)
10/232848	August 30, 2002	1303.073US1	ONE-DEVICE NON-VOLATILE
			RANDOM ACCESS MEMORY CELL
10/232846	August 30, 2002	1303.080US1	ONE TRANSISTOR SOI NON-VOLATILE
			RANDOM ACCESS MEMORY CELL
10/425483	April 29, 2003	1303.105US1	ONE TRANSISTOR SOI NON-VOLATILE
	•		RANDOM ACCESS MEMORY CELL

Respectfully submitted,

ARUP BHATTACHARYYA

By Applicant's Representatives,

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

P.O. Box 2938

Minneapolis, MN 55402

(612) 373-6960

Date 2-25-04

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Bv

Marvin L. Beekman

Reg. No. 38,377

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Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this 25th day of February, 2004.

Judish Den.

Sigh

Signature

<u>S/N 10/612793</u> <u>PATENT</u>

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Arup Bhattacharyya Examiner: Unknown

Serial No.: 10/612793 Group Art Unit: 2811

Filed: July 02, 2003 Docket: 1303.111US1

HIGH-PERFORMANCE ONE-TRANSISTOR MEMORY CELL

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

JC Kitle:

In compliance with the duty imposed by 37 C.F.R. § 1.56, and in accordance with 37 C.F.R. §§ 1.97 *et. seq.*, the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified patent application. Applicant respectfully requests that this Information Disclosure Statement be entered and the documents listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to the provisions of MPEP 609, Applicant requests that a copy of the 1449 form, initialed as being considered by the Examiner, be returned to the Applicant with the next official communication.

Pursuant to 37 C.F.R. §1.97(b), it is believed that no fee or statement is required with the Information Disclosure Statement. However, if an Office Action on the merits has been mailed, the Commissioner is hereby authorized to charge the required fees to Deposit Account No. 19-0743 in order to have this Information Disclosure Statement considered.

Filing Date: July 02, 2003

Title: HIGH-PERFORMANCE ONE-TRANSISTOR MEMORY CELL

Dkt: 1303.111US1

The present application is either a U.S. national patent application filed after June 30, 2003 or an international application that entered the national stage under 35 U.S.C. § 371 after June 30, 2003. Thus, Applicant believes that the U.S. Patent & Trademark Office has waived the requirement under 37 C.F.R. 1.98 (a)(2)(i) for submitting a copy of each cited U.S. patent and each U.S. patent application publication. The waiver is provided in a pre-OG notice from the U.S. Patent & Trademark Office entitled "Information Disclosure Statements May Be Filed Without Copies of U.S. Patents and Published Applications in Patent Applications filed after June 30, 2003" and dated July 11, 2003. Applicant acknowledges the requirement to submit copies of foreign patent documents and non-patent literature in accordance with 37 C.F.R. 1.98(a)(2).

The Examiner is invited to contact the Applicant's Representative at the below-listed telephone number if there are any questions regarding this communication.

Respectfully submitted,

ARUP BHATTACHARYYA

By his Representatives,

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A. P.O. Box 2938
Minneapolis, MN 55402
(612) 373-6960

Date 2-25-04

Marvin L. Beekma

Reg. No. 38,377

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this 25th day of February, 2004.

Name

Signature

PTO/SB/08A(10-01)
Approved for use through 10/31/2002, OMB 651-0031
US Petent & Trademark Office: U.S. DEPARTMENT OF COMMERCE
Under the Paperwork Reduction Act of 1995,no persons are required to respond to a collection of information unless it contains a valid OMB control number. Substitute for form 1449A/PTO Complete if Known INFORMATION DISCLOSURE **Application Number** 10/612793 STATEMENT BY APPLICANT (Use as many sheets as necessary) July 2,2003 **Filing Date First Named Inventor** Bhattacharyya, Arup **Group Art Unit** 2811 **Examiner Name** Unknown Attorney Docket No: 1303.111US1 Sheet 1 of 2

	US PATENT DOCUMENTS						
Examiner Initial *	USP Document Number	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	Filing Date If Appropriate	
	US-2003/0042534	03/06/2003	Bhattacharyya, Arup, et al.	257	317	08/30/2001	
	US-2003/0072126	04/17/2003	Bhattacharyya, Arup	361	311	08/30/2001	
	US-2003/0089942	05/15/2003	Bhattacharyya,Arup	257	310	11/09/2001	
	US-2003/0151948	08/14/2003	Bhattacharyya, Arup, et al.	365	185.18	02/12/2002	
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Examiner Initials*	Foreign Document No	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	T²
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EXAMINER

DATE CONSIDERED

PTO/SB/08A(10-01)

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US Patent & Trademark Office: U.S. DEPARTMENT OF COMMERCE

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INFORMATION DISCLOSURE Complete if Known 10/612793 **Application Number** STATEMENT BY APPLICANT July 2,2003 **Filing Date** (Use as many sheets as necessary) **First Named Inventor** Bhattacharyya, Arup 2811 **Group Art Unit** Unknown **Examiner Name** Attorney Docket No: 1303.111US1 Sheet 2 of 2

<u> </u>		OTHER DOCUMENTS NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the Item (book, magazine, journal, serial, symposium, catalog,etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
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